

# INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(PTO-1449)

 ATTY. DOCKET NO.  
**43889-936**

 SERIAL NO.  
 (Divisional of Serial No.  
 09/326,541)

 APPLICANT  
**Takahiro MATSUO, et al.**

 FILING DATE  
**April 17, 2000**

GROUP

 U.S. PTO  
 09/551656  
 04/18/00

## U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
GH	5,650,261	7/97	Winkle	430	270.1	10-27-89
GH	5,714,628	4/98	Matsuo	430	323	6-30-95
GH	4,869,995	9/26/89	Shirai et al.	430	270.1	
GH	4,775,609	10/4/88	McFarland	430	330	
GH	5,015,559	5/14/91	Ogawa	430	326	
GH	5,278,029	1/11/94	Shirai et al.	430	323	

## FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
GH	0 691 674	1/10/96	Europe				
GH	0 515 212	11/25/92	Europe				
GH	0 519 128	12/23/92	Europe				

## OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

GH	"Photosensitive Polymers Bearing Iminooxysulfonyl Groups. A Water Soluble Positive-Type Photoresist", by Shirai et al, Die Markomol. Chemie. Macromolecular Chemistry and Physics, Vol. 90, No. 9, pp. 2099-2107 (1989).
GH	Shirai et al, 114:63167, Chemical Abstracts, America Chemical Society, Columbus, Ohio, Abstract of J. Appl. Polym. Sci. (1990), Vol. 41, No. 9-10, pp. 2527-2532.
EXAMINER	DATE CONSIDERED
	9-27-00

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.